Simulation of Monolithic Active Pixel Sensors for ILC ECAL

CALICE UK Meeting Manchester, 3rd November 2006



Y. Mikami, N. Watson, J. Wilson University of Birmingham,

> P. Dauncey, A. Magnan Imperial College London,

J. Crooks, K. Stefanov, R. Turchetta, M. Tyndel, G.Villani Rutherford Appleton Laboratory

Outline

- Introduction
- MAPS (Monolithic Active Pixel Sensors)
 - Concepts
 - > Design
- Geometry modification

Single e-/μ- simulation

- > Si sensitive thickness dependence
- > Cell size dependence
- Incoming energy dependence
- Summary of status
- Future prospects

Introduction

High granularity

- Small cells
 - Digital Calorimetry

Cost saving

- > Using CMOS silicon
 - Cheaper than high resistance pure silicon

Si thickness reduction Reduction of outer sub-detector volume

MAPS concepts

 Detecting individual particles after electromagnetic cascade shower by small cells

Result in measuring a single particle in a cell

- > Binary readout
 - Digital calorimetry
 →High granularity

MAPS design

- > Analogue design
- 1cm X 1cm cell
- 500µm Si sensitive thickness
- 500µm Si physical thickness
- Analogue readout

- > MAPS design
- 50µm X 50µm cell
- ~15µm Si sensitive thickness
- 300µm Si physical thickness
- Binary readout
- One PCB per layer

W thickness is the same with both cases.

Geometry modification

Default



800μm 500μm 800μm

- Mokka 06-00
- Ecal02.cc (Geant4 ECAL driver) is modified.
- Geant4 Adaptive GUI output is fine.
- Energy deposit agreed with the expect.
 - (i.e.15µm/500µm =3.0%)
- Layer position shift agreed with the expect.



Single e- simulation (1.a) (Si sensitive thickness dependence)

20 GeV single electron (from IP to zenith with magnet on) Cell size is 1cm X 1cm



No threshold is applied for energy of cell hits

Single e- simulation (1.b) (Si sensitive thickness dependence)

20 GeV single electron Cell size is 1cm X 1cm

Number of cell hits with Si sensitive thickness dependence



Only a few % dependence

Single e-/µ- simulation (2)

15μm Si sensitive thickness 50μm X 50μm cell size



Single e- simulation (3.a) (Cell size dependence)



Single e- simulation (3.b) (Cell size dependence)



- One MIP per cell
- One MIP's energy deposit is sharing by neighbour cell

Single e- simulation (3.c) (Cell size dependence: consistency checks)



100GeV e-15μm Si sensitive



Single e- simulation (4) (Incoming energy dependence)



Summary of status

- MAPS test geometry is implemented.
- Each cell has only one MIP in most case.
- Charge sharing by neighbour cell is seen.
- 50μm X 50μm cell seems to be reasonable.
- Sensor level simulation is ongoing as well. (Giulio Villani et al. -> please see Konstantin Stefanov's talk at calorimetry session.)

Future Prospects

Resolution studies

- Clustering algorithm development
 - It can be developed only with shower topology.
 - (i.e. Each cell hit has identical energy.)
 - Sophisticated algorithm to save CPU time in this Tera pixel study.

Physics events studies

Backup: Readout by 48 contiguous cells (Under study as one option)

100GeV single e-15μm Si sensitive thickness 50μm X 50μm cell size



Total energy also increased 30% compared with single cell.